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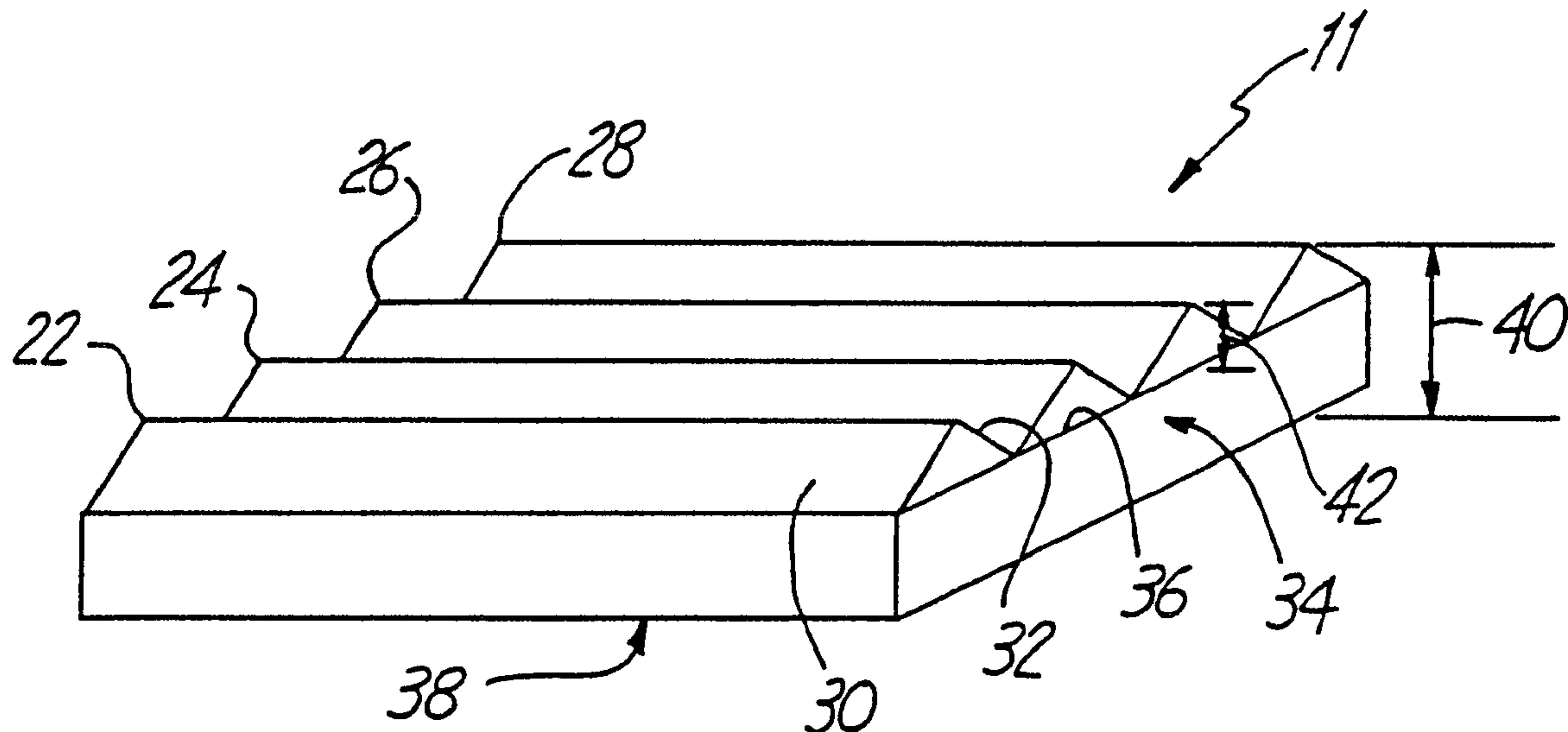
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RENFORCEMENT DE LA LUMINOSITE

(54) Title: PREVENTION OF GROOVE TIP DEFORMATION IN BRIGHTNESS ENHANCEMENT FILM

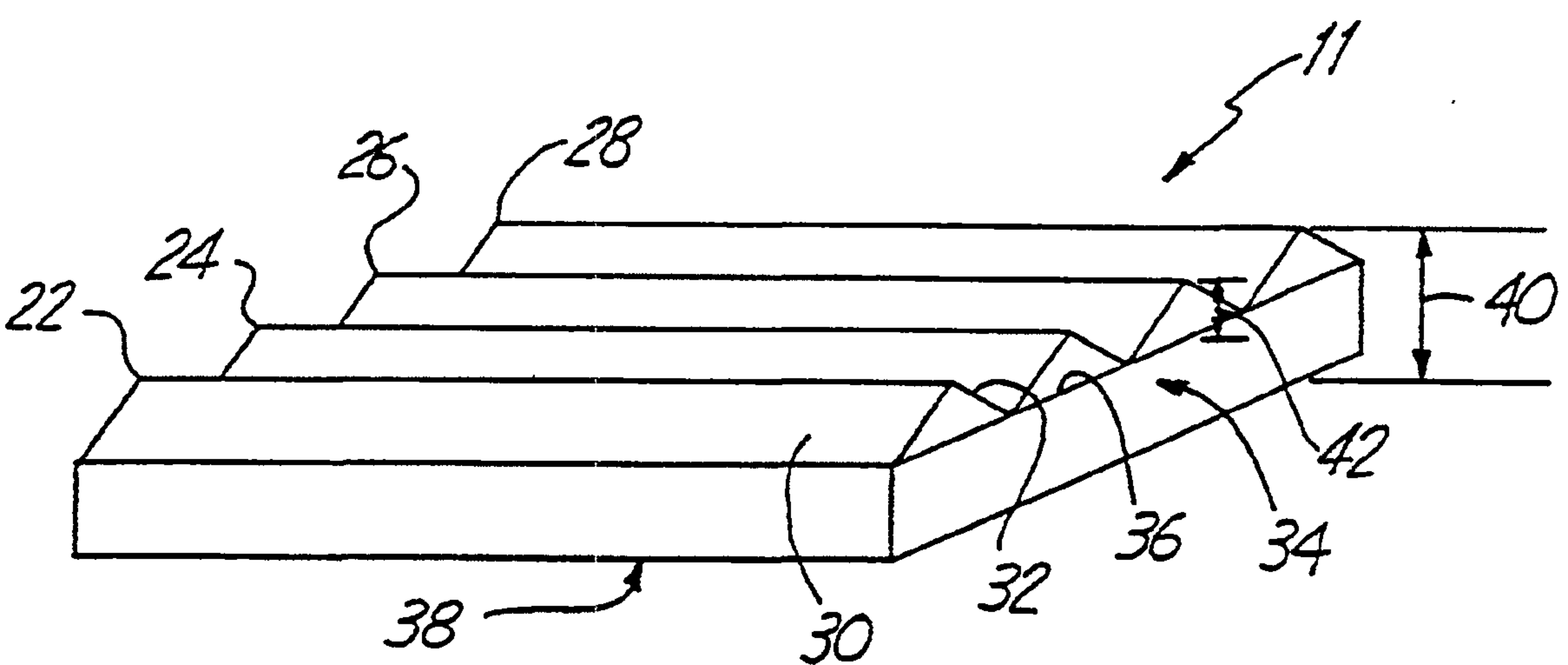


(57) Abrégé/Abstract:

A method of producing a microstructure bearing article (11) that includes the steps of molding the microstructure (22, 24, 26, 28) on the base (34), curing the resin that forms the microstructure, and heat treating the microstructure. The heat treating is performed at a temperature that is at least equal to a normal glass transition temperature of the resin. The heat treating raises the glass transition temperature of the resulting polymer above approximately 333 °K such that groove tip impression is reduced. Such articles are useful in backlit displays (10) which are useful in computers and the like.

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| <b>(21) International Application Number:</b> PCT/US95/16270<br><b>(22) International Filing Date:</b> 18 December 1995 (18.12.95)<br><b>(30) Priority Data:</b><br>08/382,997                      3 February 1995 (03.02.95)                      US<br><b>(71) Applicant:</b> MINNESOTA MINING AND MANUFACTURING COMPANY [US/US]; 3M Center, P.O. Box 33427, Saint Paul, MN 55133-3427 (US).<br><b>(72) Inventors:</b> WILLIAMS, Todd, R.; P.O. Box 33427, Saint Paul, MN 55133-3427 (US). KINGSTON, Daniel, J.; P.O. Box 33427, Saint Paul, MN 55133-3427 (US).<br><b>(74) Agents:</b> JORDAN, Robert, H. et al.; Minnesota Mining and Manufacturing Company, Office of Intellectual Property Counsel, P.O. Box 33427, Saint Paul, MN 55133-3427 (US).                                                                                            |           | <b>(81) Designated States:</b> AL, AM, AT, AU, BB, BG, BR, BY, CA, CH, CN, CZ, DE, DK, EE, ES, FI, GB, GE, HU, IS, JP, KE, KG, KP, KR, KZ, LK, LR, LS, LT, LU, LV, MD, MG, MN, MW, MX, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, TJ, TM, TT, UA, UG, UZ, VN, ARIPO patent (KE, LS, MW, SD, SZ, UG), European patent (AT, BE, CH, DE, DK, ES, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE), OAPI patent (BF, BJ, CF, CG, CI, CM, GA, GN, ML, MR, NE, SN, TD, TG).<br><br><b>Published</b><br><i>With international search report.</i><br><i>Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.</i> |
| <b>(54) Title:</b> PREVENTION OF GROOVE TIP DEFORMATION IN BRIGHTNESS ENHANCEMENT FILM<br><br><br><b>(57) Abstract</b><br><p>A method of producing a microstructure bearing article (11) that includes the steps of molding the microstructure (22, 24, 26, 28) on the base (34), curing the resin that forms the microstructure, and heat treating the microstructure. The heat treating is performed at a temperature that is at least equal to a normal glass transition temperature of the resin. The heat treating raises the glass transition temperature of the resulting polymer above approximately 333 °K such that groove tip impression is reduced. Such articles are useful in backlit displays (10) which are useful in computers and the like.</p> |           |                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                                              |

**PREVENTION OF GROOVE TIP DEFORMATION IN  
BRIGHTNESS ENHANCEMENT FILM  
BACKGROUND OF THE INVENTION**

5       The present invention relates generally to a method of producing a  
microstructure bearing composite article that exhibits superior tip deformation  
resistance qualities. More particularly, the present invention relates to a method of  
reducing groove tip impression in a brightness enhancement film, in which the key  
geometrical features of useful brightness enhancement film articles are disclosed.

10       The use of the microstructure bearing article as a brightness  
enhancement film is shown in Whitehead, U.S. Patent No. 4,542,449. One example  
of a microstructure bearing article, which is useful as a brightness enhancement film,  
is described in Lu et al., U.S. Patent No. 5,175,030, and Lu, U.S. Patent No.  
5,183,597. These patents disclose microstructure bearing composite plastic articles  
and a method of molding the microstructure bearing composite plastic articles. The  
15   Lu et al. patent and the Lu patent address forming the microstructure with desired  
optical properties, such as total internal reflection.

      Microstructure bearing articles are made in a variety of forms. One  
such form includes a series of alternating tips and grooves. One example of such a  
form is brightness enhancement film, which has a regular repeating pattern of  
20   symmetrical tips and grooves. Other examples include patterns in which the tips and  
grooves are not symmetrical and in which the size, orientation, or distance between  
the tips and grooves is not uniform.

      One major draw back of prior art radiation cured brightness  
enhancement films is that dark spots were occasionally seen in prior art brightness  
25   enhancement films. While the dark spots do not affect the measured brightness  
enhancement of the product, the dark spots are undesirable because the spots  
detrimentally affect the cosmetic appearance of the brightness enhancement film. As  
a result, manufacturers of displays desire brightness enhancement films that do not  
have such dark spots.

30       Prior art brightness enhancement films include "Brightness  
Enhancement Film", a version made from polycarbonate thermoplastic, sold by

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Minnesota Mining and Manufacturing Company, St. Paul, Minnesota and "DIAART" a version made of a radiation cured microstructured layer on a polyester base, sold by Mitsubishi Rayon, Tokyo, Japan.

5

SUMMARY OF THE INVENTION

The present invention provides a method of producing a microstructure bearing article that includes the steps of molding the alternating tips and grooves on the base, curing the resin that forms the tips and grooves, and  
10 heat treating the tips and grooves. The heat treating is performed at a temperature that is at least equal to a normal glass transition temperature of the resin and may be done simultaneously with curing the resin (curing at an elevated temperature) or as a post cure treatment. The heat  
15 treating is effective to raise the glass transition temperature of the resulting polymer above approximately 333°K such that groove tip impression is reduced. In addition, a crosslinking agent may be added to help in raising the glass transition temperature.

20 The invention also provides backlit displays comprising such articles and computers comprising such displays.

According to one aspect of the present invention, there is provided a method of improving groove tip  
25 impression resistance in a microstructure bearing article, comprising: forming a desired microstructure in a first layer on a base from an oligomeric resin; curing the resin of the first layer; and heat treating the first layer at a temperature that is at least equal to a normal glass  
30 transition temperature of the resin, the heat treating

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raising the glass transition temperature of the resulting polymer above about 333°K such that groove tip impression is reduced.

According to another aspect of the present invention, there is provided a method of improving groove tip impression resistance in a microstructure bearing article comprising: preparing an oligomeric resin composition; depositing the oligomeric resin composition onto a master negative microstructured surface or onto the substrate in an amount barely sufficient to fill cavities of the master; filling the cavities by moving a bead of the oligomeric resin composition between the substrate and the master, at least one of which is flexible, the oligomeric resin composition forming a desired microstructure; curing the oligomeric resin that forms the desired microstructure; and heat treating the desired microstructure at a temperature that is at least equal to a normal glass transition temperature of the resin, the heat treating raising the glass transition temperature of the resulting polymer above about 333°K such that groove tip impression is reduced.

According to still another aspect of the present invention, there is provided a microstructure bearing article wherein the article exhibits reduced groove tip impression and comprises: a base; and a microstructure formed from a crosslinkable oligomeric resin on the base, and wherein the microstructure bearing article exhibits a glass transition temperature sufficiently above the normal glass transition temperature such that groove tip impression is reduced.

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According to yet another aspect of the present invention, there is provided a backlit display comprising: a light source; a display panel; and a microstructure bearing article as described herein disposed between the light  
5 source and the display panel.

According to a further aspect of the present invention, there is provided a computer display terminal comprising: a light source; a display panel; and a microstructure bearing article as described herein disposed  
10 between the light source and display panel.

#### BRIEF DESCRIPTION OF THE DRAWINGS

Figure 1 is a schematic view of an illustrative film of the present invention in the backlit liquid crystal display.

15 Figure 2 is a perspective view of an illustrative microstructure bearing polymeric article of the present invention.

Figure 3 is a graph of groove tip impression penetration versus glass transition temperature for  
20 brightness enhancement films produced according to the method of the present invention.

Figures 1 and 2, which are not to scale, are intended to be merely illustrative and non-limiting.

#### DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

25 The present invention provides a method of producing a microstructure bearing polymeric article having alternating grooves and tips on a base or substrate that is

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resistant to groove tip impression. The terms "base" and "substrate" are used interchangeably herein. The method according to the present

invention provides for the formation of a microstructure bearing article that resists groove tip deformation when used as a brightness enhancement film.

An illustrative backlit liquid crystal display generally indicated at 10 in Figure 1 includes a brightness enhancement film 11 of the present invention, which is typically positioned between a diffuser 12 and a liquid crystal display panel 14. The backlit liquid crystal display also includes a light source 16 such as a fluorescent lamp, a light guide 18 for transporting light for reflection toward the liquid crystal display panel 14, and white reflector 20 for reflecting light also toward the liquid crystal display panel. The brightness enhancement film 11 collimates light emitted from the light guide 18 thereby increasing the brightness of the liquid crystal display panel 14. The increased brightness enables a sharper image to be produced by the liquid crystal display panel and allows the power of the light source 16 to be reduced to produce a selected brightness. The brightness enhancement film 11 in the backlit liquid crystal display is useful in equipment such as computers, personal televisions, video recorders, mobile communication devices, and automobile and avionic instrument displays, represented by reference character 21. The brightness enhancement film 11 includes an array of prisms typified by prisms 22, 24, 26, and 28, as illustrated in Figure 2. Each prism, for example, such as prism 22, has a first facet 30 and a second facet 32. The prisms 22, 24, 26, and 28 are formed on a body portion 34 that has a first surface 36 on which the prisms are formed and a second surface 38 that is substantially flat or planar and opposite the first surface.

A linear array of regular right prisms is preferred for both optical performance and ease of manufacture. By right prisms, it is meant that the apex angle  $\Theta$  is typically  $90^\circ$ , but can also range from  $70^\circ$  to  $120^\circ$  and most preferably from  $80^\circ$  to  $100^\circ$ . The prism facets need not be identical, and the prisms may be tilted with respect to each other. Furthermore, the relationship between the thickness 40 of the film and the height 42 of the prisms is not critical, but it is desirable to use thinner films with well defined prism facets. A typical ratio of prism height 42 to total thickness 40 is generally between 25/125 and 2/125.

The angle that the facets would form with the surface 38 if the facets were to be projected would typically be 45°. However, this angle would vary depending on the pitch of the facet or the angle  $\Theta$  of the apex.

It has been discovered that the dark spots seen with the prior art  
5 radiation cured brightness enhancement films were caused by deformation in the tips of the brightness enhancement film. Tip deformation commonly results when a weight or force is placed on the brightness enhancement film or when an object strikes the brightness enhancement film. Tip deformation is used herein synonymously with groove tip impression.

10 It has also been discovered that when the glass transition temperature of the polymer used in the brightness enhancement film is raised above about 333°K, the brightness enhancement film becomes more resistant to groove tip impression. 333°K is above the normal glass transition temperature of the polymer used in the brightness enhancement film. The normal glass transition temperature is the glass  
15 transition temperature obtained when the polymer is cured by ultraviolet radiation at ambient temperature.

Elevation of the glass transition temperature can be accomplished using a variety of methods. For example, the glass transition temperature can be changed over a broad range by elevating the temperature while the brightness  
20 enhancement film is cured. The glass transition temperature can also be elevated by subjecting the brightness enhancement film to a post-cure heat treatment and by adding crosslinking materials.

The microstructure bearing article is preferably formed according to a process similar to the processes disclosed in Lu et al., U.S. Patent No. 5,175,030,  
25 and Lu, U.S. Patent No. 5,183,597. The formation process preferably includes the following steps:

- (a) preparing an oligomeric resin composition;
- (b) depositing the oligomeric resin composition onto a master negative microstructured molding surface in an amount barely  
30 sufficient to fill the cavities of the master;

- (c) filling the cavities by moving a bead of the composition between a preformed substrate and the master, at least one of which is flexible; and
- (d) curing the oligomeric composition.

5           The oligomeric resin composition of step (a) is a one-part, solvent-free, radiation-polymerizable, crosslinkable, organic oligomeric composition. The oligomeric composition is preferably one which gives a cured polymer of high refractive index, that is a refractive index above 1.56 and preferably above 1.58. The high refractive index is beneficial to the optical performance of the brightness  
10 enhancement film. One preferred suitable oligomeric composition is a blend of aromatic epoxy-derived acrylate or multi-acrylate and one or more reactive diluents (used to control viscosity of the composition), preferably including at least one acrylate ester containing an aromatic group. This combination provides a cured resin with an acceptable combination of high refractive index and high glass transition  
15 temperature.

          In the preferred oligomeric resin composition, the epoxy acrylate or multiacrylate is between about 40 and 80 percent by weight and preferably between about 55 and 65 percent by weight of the oligomeric composition. The reactive diluent(s) is between about 20 and 60 percent by weight and preferably between  
20 about 35 and 45 percent by weight of the oligomeric composition.

          For brightness enhancement films, high refractive index is beneficial to the optical performance. Therefore, the oligomeric composition also preferably gives a cured polymer of a high refractive index, that is a refractive index above 1.56.

25           The epoxy diacrylate can be chosen from a number of such compounds available commercially, such as the "PHOTOMER" Brand series: 3015, 3016, and 3038 (from Henkel Corp., Ambler, Pennsylvania), and the "EBECRYL" Brand series: 600, 1608, 3201, 3500, and 3600 (from UCB-Radcure, Smyrna, Georgia). Key criteria in selecting an oligomer are refractive index and  
30 homopolymer glass transition temperature. Increasing the number of atoms connecting the acrylate groups and the aromatic groups will typically reduce both

refractive index and glass transition temperature, but may increase flexibility of the cured resin. Such connecting groups are often in the form of ethoxy or propoxy groups.

The epoxy diacrylate can also be modified by addition of bromine.

- 5 The bromine modified epoxy diacrylate is preferably RDX 51027, which has about two bromine atoms on each phenyl group. RDX 51027 can be obtained from UCB-Radcure of Smyrna, Georgia.

- Monomers are typically added to radiation curable oligomeric resin compositions to reduce the normally high viscosity of the oligomer. Such monomers  
10 may also be used to modify properties of the cured resin, such as flexibility, refractive index, and glass transition temperature. Examples of such monomers are listed in U.S. Patent No. 4,668,558 along with the normal glass transition temperatures of their homopolymers and include isobornyl acrylate (367°K), methyl methacrylate (378°K), cyclohexylchloroacrylate (372°K), 2-chlorostyrene (406°K),  
15 2,4-dichlorostyrene (406°K), styrene (373°K), acrylic acid (360°K), acrylamide, acrylonitrile (393°K), methacrylonitrile (393°K). High reactivity monomers that have high refractive indices, such as phenoxyethyl acrylate and benzyl acrylate, are especially preferred.

- Acrylate functional monomers and oligomers are preferred because  
20 they polymerize more quickly under normal curing conditions. Further, a large variety of acrylate esters are commercially available. However, methacrylate, acrylamide and methacrylamide functional ingredients can also be used without restriction. Herein, where "acrylate" is used, "methacrylate" is understood as being acceptable. Styryl functional monomers can be included, but usually in relatively  
25 minor amounts to ensure complete polymerization, especially with radiation curing.

- Polymerization can be accomplished by usual means, such as heating in the presence of free radical initiators, irradiation with ultraviolet or visible light in the presence of suitable photoinitiators, and by irradiation with electron beam. For reasons of convenience, low capital investment, and production speed, the preferred  
30 method of polymerization is by irradiation with ultraviolet or visible light in the presence of photoinitiator at a concentration of about 0.1 percent to about 1.0 percent

by weight of the oligomeric composition. Higher concentrations can be used but are not normally needed to obtain the desired cured resin properties.

The viscosity of the oligomeric composition deposited in step (b) is preferably between 500 and 5,000 centipoise (500 and  $5,000 \times 10^{-3}$  pascal-seconds).

5 If the oligomeric composition has a viscosity above this range, air bubbles might become entrapped in the composition. Additionally, the composition might not completely fill the cavities in the master. When an oligomeric composition with a viscosity below that range is used, the oligomeric composition usually experiences shrinkage upon curing that prevents the oligomeric composition from accurately  
10 replicating the master.

Polyethylene terephthalate or polycarbonate film are preferable for use as a substrate in step (c) because the materials are economical, optically clear, and have good tensile strength. Thicknesses of 0.025 millimeters to 0.5 millimeters are preferred and thicknesses of 0.075 millimeters to 0.175 millimeters are especially  
15 preferred.

Almost any material can be used for the base (substrate), as long as that material is substantially optically clear, has enough strength to allow handling during casting of the microstructure, and manufacture of a display assembly in which the microstructure bearing article is used. In addition, the material used for the base  
20 should be chosen so that it has sufficient thermostability and resistance to aging so that performance of the display assembly in which the article of the present invention is used is not compromised over its typical lifetime.

Other useful substrates for the microstructure bearing articles include cellulose acetate butyrate, cellulose acetate propionate, polyether sulfone, polymethyl  
25 methacrylate, polyurethane, polyester, polyvinyl chloride, and glass. The surface of the substrate may also be treated to promote adhesion to the oligomeric composition.

Polyethylene terephthalate base materials having good optical qualities and acceptable adhesion are preferred. Examples of such polyethylene terephthalate based materials include: a photograde polyethylene terephthalate; a polyethylene  
30 terephthalate (PET) having a surface that is formed according to the method described in U.S. Patent No. 4,340,276 (Example 5), referred to herein as "SEP-

PET"; and MELINEX PET manufactured by ICI Films of Wilmington, Delaware. The SEP-PET has a material such as chromium applied in an amount which results in a composite surface on which portions of the underlying PET are exposed between discontinuous microislands of the material. The composite surface is sputter etched  
5 with an oxygen plasma to preferentially etch the exposed portions of the higher sputtering rate PET, while the discontinuous microislands are etched at a lower rate, resulting in a topography of micropedestals which vary in height within a range of approximately 0.01 and 0.2  $\mu\text{m}$  and which are separated from adjacent micropedestals a distance within a range of approximately 0.05 to 0.5  $\mu\text{m}$ .

10 A preferred master for use with the above described method is a metallic master, such as nickel, nickel-plated copper or brass. If the temperature of the curing and optionally simultaneous heat treating step is not too great, the master can also be constructed from a thermoplastic material, such as a laminate of polyethylene and polypropylene.

15 After the oligomeric resin fills the cavities between the substrate and the master, the oligomeric resin is cured and heat treated. Curing and heat treating is preferably accomplished using one of the following methods.

A first method includes radiation curing of the resin at an elevated temperature. The preferred resins are curable using radiation, such as from  
20 ultraviolet light or from an electron beam, which is conventionally conducted at room temperature. Curing the resin at an elevated temperature raises the glass transition temperature of the resultant article to an extent that reduces groove tip impression to a satisfactory level.

In this embodiment, the resin is cured at a temperature at least equal  
25 to the desired glass transition temperature and preferably above the desired glass transition temperature. The resin is preferably cured at a temperature of at least 10°C (10°K) above the normal glass transition temperature and most preferably at a temperature of at least 20°C (20°K) above the normal glass transition temperature. For the oligomeric composition that is a blend of epoxy diacrylate and phenoxyethyl  
30 acrylate, the cure temperature is preferably about 85°C (385°K).

A second method includes curing the resin and then subjecting the

resin to a post-cure heat treatment. The post-cure heat treatment involves heating the cured resin at a temperature at least equal to the normal glass transition temperature of the polymer for approximately 60 seconds. The heating temperature is preferably at least 10°C (10°K), and most preferably at least 20°C (20°K), above the normal  
5 glass transition temperature.

A third method includes adding a crosslinking agent to the resin to further aid in the crosslinking of the polymer, which will also result in elevation of the glass transition temperature. Illustrative examples of suitable crosslinking agents include 1,4-butylene di-methacrylate or -acrylate; ethylene di-methacrylate or  
10 -acrylate; trimethylolpropane di- or tri-acrylate; glyceryl di-acrylate or -methacrylate; glyceryl tri-acrylate or -methacrylate; glycidyl acrylate or methacrylate; pentaerythritol tri- or tetra-acrylate or tri- or tetra-methacrylate; diallyl phthalate; 2,2-bis(4-methacryloxyphenyl)- propane; diallyl adipate; di(2-acryloxyethyl) ether; dipentaerythritol pentacrylate; neopentyl glycol diacrylate; polypropylene glycol  
15 diacrylate or dimethacrylate; 1,3,5-tri-(2-(meth)acryloxyethyl)-s-triazine; hexamethylene diacrylate; poly(ethylenically unsaturated alkoxy) heterocycles, as taught in U.S. Patent No. 4,262,072; and adducts of poly(isocyanates) with hydroxy- and amino- functional acrylates, such as EB 220 sold by UCB-Radcure of Smyrna, Georgia. Crosslinking agents are preferred that result in a polymer with a high  
20 refractive index. Preferably, the refractive index is greater than 1.56 and most preferably the refractive index is greater than 1.58. One such crosslinking agent, which is especially useful, is EB 220.

Preferably, all three methods are combined. A crosslinking agent is added to the resin and the resin is cured at an elevated temperature and then subjected  
25 to a post-cure heat treatment. Alternatively, any of the two methods may also be combined such as adding a crosslinking agent to the resin and then curing the resin at an elevated temperature or the resin is cured at an elevated temperature and then subjected to post-cure heat treatment. A crosslinking agent may be added to the resin which is then cured at ambient temperature while post-cured at a temperature at least  
30 equal to the normal glass transition temperature as described previously.

The resin is post-cure heat treated at a temperature at least equal the normal glass transition temperature for 30 to 60 seconds. The post-cure heat treatment is preferably at a temperature of at least 10°C (10°K) above the glass transition temperature and most preferably at a temperature of greater than 20°C (20°K) above the glass transition temperature. For the oligomeric composition that is a blend of epoxy diacrylate and phenoxyethyl acrylate, the post-cure heat treatment is preferably at a temperature between 80°C (353°K) and 110°C (383°K) for 60 seconds.

A testing method has also been developed to define satisfactory groove tip impression resistance of the brightness enhancement film of the present invention. The test measures groove tip impression penetration. In most cases, the groove tip impression penetration test has been found to provide a good correlation to visible groove tip impressions.

The groove tip impression penetration is measured according to the following test procedure. The groove tip impression penetration test is preferably conducted on a table floating on an air cushion to minimize the external effects on the groove tip impression penetration results.

The brightness enhancement film is cut into a 100 mm square. A flat and smooth glass plate is placed on the air cushioned table. The brightness enhancement film is then placed on the glass plate. The grooves in the brightness enhancement film are oriented in the up direction.

Three steel balls are affixed to one side of a circular steel plate in a triangular orientation. The steel balls preferably have a diameter of 3 mm. The steel plate preferably has a diameter of 100 mm. The steel balls and steel plate unit weighs approximately 600 grams.

The steel plate is then placed on the brightness enhancement film sample with the steel balls oriented against the brightness enhancement film. Additional steel plates, weighing approximately 3,327 grams, may also be placed on the 100 mm diameter steel plate.

After dwelling on the brightness enhancement film for 30 minutes, the balls and the steel plates are removed from the brightness enhancement film. The

penetration of the steel balls into the brightness enhancement film is measured using a Supramess Mahr dial indicator having 0.000002 inch (0.05 micron) increments. The Supramess Mahr dial indicator is preferably mounted on a Ono Sokki ST-022 gauge stand.

5           The glass transition temperature is preferably measured as a peak in the  $\tan \delta$  curve obtained from dynamic mechanical analysis of the composite in tensile mode using a dynamic mechanical analyzer, such as a Rheometrics RSA-II.

10           All of the curing and heat treating methods for increasing the glass transition temperature have been used and it appears not to make a difference as to which method is used. As long as the glass transition temperature is elevated, the groove tip impression penetration is reduced.

15           The groove tip impression penetration results from several samples of brightness enhancement film are illustrated in Figure 3. From these results it can be seen that there is a good correlation between groove tip impression penetration and glass transition temperature.

20           The tests were conducted using two types of brightness enhancement film. One type of brightness enhancement film contains brominated resin and the other type of brightness enhancement film contains unbrominated resin. The brominated resin contains 60 percent by weight RDX 51027 and 40 percent by weight PHOTOMER Brand 4035. The unbrominated resin contains 60 percent by weight PHOTOMER Brand 3016 and 40 percent by weight PHOTOMER Brand 4035.

25           From Figure 3, it can be seen that the unbrominated resin and brominated resin fall on the same general curve. Based on these results, it can be concluded that the relationship between groove tip impression penetration and glass transition temperature is a physical relationship, which is not dependent upon composition. Similarly, since low groove tip impression penetration is correlated to reduced groove tip impression, the glass transition temperature relates similarly to groove tip impression.

30           As can be seen from the curve in Figure 3, several samples of ultraviolet radiation cured brightness enhancement film composites have been

prepared that exhibit very low groove tip impression penetration. For nearly all of these samples, the groove tip impression penetration is less than  $4.0 \times 10^{-6}$  inches (0.1 microns). These results are a significant improvement over previously prepared samples.

5                   For most applications of brightness enhancement film, the use temperature is very close to normal room temperature of approximately 20°C (293°K). However, some display manufacturers require testing of all their components at 65°C (338°K). With prior art brightness enhancement film, even  
10                   when cured at elevated temperature, the glass transition temperature is not high enough to avoid groove tip impressions at the elevated testing temperature. This is especially true in situations in which two pieces of brightness enhancement film are used one on top of the other with grooves crossed, as in Whitehead, U.S. Patent 4,542,449.

                  The glass transition temperature of the brightness enhancement film  
15                   resin can be raised by the inclusion of additional crosslinking agents, as described above, and by utilizing the elevated cure temperature method disclosed herein as illustrated in the Table. The item indicated as "HHA" is hydantoin hexaacrylate, which was prepared according to Wendling et al., U.S. Patent No. 4,262,072. Sample E was prepared with the crosslinking agent EB 220. These data show clearly  
20                   that the glass transition temperature of the brightness enhancement film resin can be raised significantly with minimal decrease of refractive index by proper choice of crosslinking agents and curing conditions.

TABLE

|                                   | Sample |       |       |       |       |
|-----------------------------------|--------|-------|-------|-------|-------|
|                                   | A      | B     | C     | D     | E     |
| <b>Component</b>                  |        |       |       |       |       |
| RDX 51027 (%)                     | 60     | 60    | 51    | 42    | 51    |
| PHOTOMER 4035 (%)                 | 40     | 40    | 34    | 28    | 34    |
| HHA (%)                           |        |       | 15    | 30    |       |
| EB 220 (%)                        |        |       |       |       | 15    |
| <b>Properties</b>                 |        |       |       |       |       |
| Cure Temperature (°K)             | 298    | 373   | 373   | 373   | 373   |
| Glass Transition Temperature (°K) | 311    | 339   | 348   | 353   | 353   |
| Refractive Index                  | 1.589  | 1.593 | 1.577 | 1.567 | 1.580 |

Although the present invention has been described with reference to preferred embodiments, workers skilled in the art will recognize that changes may be made in form and detail without departing from the spirit and scope of the invention.

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CLAIMS:

1.           A method of improving groove tip impression resistance in a microstructure bearing article, comprising:  
  
              forming a desired microstructure in a first layer  
5   on a base from an oligomeric resin;  
  
              curing the resin of the first layer; and  
  
              heat treating the first layer at a temperature that is at least equal to a normal glass transition temperature of the resin, the heat treating raising the  
10 glass transition temperature of the resulting polymer above about 333°K such that groove tip impression is reduced.
2.           The method of claim 1 wherein the microstructure has adjacent polymeric tips and grooves, and the tips have an included angle in the approximate range of 70° to 120°.
- 15 3.           The method of claim 1 wherein the microstructure has adjacent polymeric tips and grooves, and the tips have an included angle in the approximate range of 80° to 100°.
4.           The method of any one of claims 1 to 3, wherein the curing is performed prior to the heat treating step.
- 20 5.           The method of any one of claims 1 to 3, wherein the curing and the heat treating are performed simultaneously.
6.           The method of any one of claims 1 to 5, wherein the oligomeric resin is crosslinkable.
- 25 7.           The method of any one of claims 1 to 5, wherein the oligomeric resin further comprises crosslinking agents to raise the glass transition temperature of the resulting

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polymer above the normal glass transition temperature such that groove tip impression is reduced.

8. The method of any one of claims 1 to 5, wherein crosslinking is initiated by ultraviolet radiation.

5 9. The method of any one of claims 1 to 8, wherein the heat treating is performed at a temperature that is at least 10 degrees Kelvin greater than the normal glass transition temperature of the resin.

10. The method of any one of claims 1 to 8, wherein  
10 the heat treating is performed at a temperature that is at least 20 degrees Kelvin greater than the normal glass transition temperature of the resin.

11. The method of any one of claims 1 to 10, further characterized in that the heat treating reduces groove tip  
15 impression penetration to less than  $1 \times 10^{-4}$  mm.

12. The method of any one of claims 1 to 11, further characterized in that the base has a sputter etched surface adjacent the first layer.

13. The method of any one of claims 1 to 12, further  
20 characterized in that said oligomeric resin comprises a photoinitiator.

14. A method of improving groove tip impression resistance in a microstructure bearing article comprising:

preparing an oligomeric resin composition;

25 depositing the oligomeric resin composition onto a master negative microstructured surface or onto the substrate in an amount barely sufficient to fill cavities of the master;

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filling the cavities by moving a bead of the oligomeric resin composition between the substrate and the master, at least one of which is flexible, the oligomeric resin composition forming a desired microstructure;

5           curing the oligomeric resin that forms the desired microstructure; and

          heat treating the desired microstructure at a temperature that is at least equal to a normal glass transition temperature of the resin, the heat treating  
10   raising the glass transition temperature of the resulting polymer above about 333°K such that groove tip impression is reduced.

15.       A microstructure bearing article wherein the article exhibits reduced groove tip impression and  
15   comprises:

          a base; and

          a microstructure formed from a crosslinkable oligomeric resin on the base, and wherein the microstructure bearing article exhibits a glass transition temperature  
20   sufficiently above the normal glass transition temperature such that groove tip impression is reduced.

16.       The microstructure bearing article of claim 15, wherein the microstructure includes adjacent tips and grooves, and the tips have an included angle in an  
25   approximate range of 70° to 120°.

17.       The microstructure bearing article of claim 15, wherein the microstructure includes adjacent tips and grooves, and the tips have an included angle in an approximate range 80° to 100°.

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18. The microstructure bearing article of claim 15, wherein the microstructure includes adjacent tips and grooves, and groove tip impression penetration is less than  $1 \times 10^{-4}$  mm.

5 19. The microstructure bearing article of any one of claims 15 to 18, wherein the oligomeric resin provides a cured polymer having a refractive index that is greater than 1.56.

10 20. The microstructure bearing article of any one of claims 15 to 18, wherein the oligomeric resin provides a cured polymer having a refractive index that is greater than 1.58.

15 21. The microstructure bearing article of any one of claims 15 to 20, wherein the base is formed from one or more of: polyethylene terephthalate, polycarbonate, cellulose acetate butyrate, cellulose acetate propionate, polyether sulfone, polymethyl methacrylate, polyurethane, polyester, polyvinyl chloride and glass.

20 22. The microstructure bearing article of any one of claims 15 to 20, wherein the resin is made from one or more of: epoxy diacrylate, bromine modified epoxy diacrylate, isobornyl acrylate, methyl methacrylate, cyclohexylchloroacrylate, 2-chlorostyrene, 2,4-dichlorostyrene, styrene, acrylic acid, acrylamide, 25 acrylonitrile, methacrylonitrile, phenoxyethyl acrylate, tribromophenoxyethyl acrylate, benzyl acrylate, alkoxylated epoxy diacrylate and bromine modified alkoxylated epoxy diacrylate.

30 23. The microstructure bearing article of any one of claims 15 to 20, wherein the crosslinkable oligomeric resin

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further includes a crosslinking agent that is added in an amount that is sufficient to raise the glass transition temperature of the crosslinkable oligomeric resin above the normal glass transition temperature such that groove tip  
5 impression is reduced.

24. The microstructure bearing article of any one of claims 15 to 20, wherein the resin comprises at least one of the following crosslinking agents: 1,4-butylene di-methacrylate or -acrylate; ethylene di-methacrylate or  
10 -acrylate; trimethylolpropane di- or tri-acrylate; glyceryl di-acrylate or -methacrylate; glyceryl tri-acrylate or -methacrylate; glycidyl acrylate or methacrylate; pentaerythritol tri- or tetra-acrylate or tri- or tetra-methacrylate; diallyl phthalate;  
15 2,2-bis(4-methacryloxyphenyl)-propane; diallyl adipate; di(2-acryloxyethyl) ether; dipentaerythritol pentacrylate; neopentyl glycol diacrylate; polypropylene glycol diacrylate or dimethacrylate; 1,3,5-tri-(2-(meth)acryloxyethyl)-s-triazine; hexamethylene diacrylate; poly(ethylenically  
20 unsaturated alkoxy) heterocycles; and adducts of poly(isocyanates) with hydroxy- and amino-functional acrylates.

25. The microstructure bearing article of any one of claims 15 to 24, wherein the base has a sputter etched  
25 surface adjacent the microstructure.

26. A backlit display comprising:  
  
a light source;  
  
a display panel; and

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a microstructure bearing article as defined in any one of claims 15 to 25 disposed between the light source and the display panel.

27. The backlit display of claim 26, wherein the  
5 display panel is a liquid crystal display panel.

28. A computer display terminal comprising:

a light source;

a display panel; and

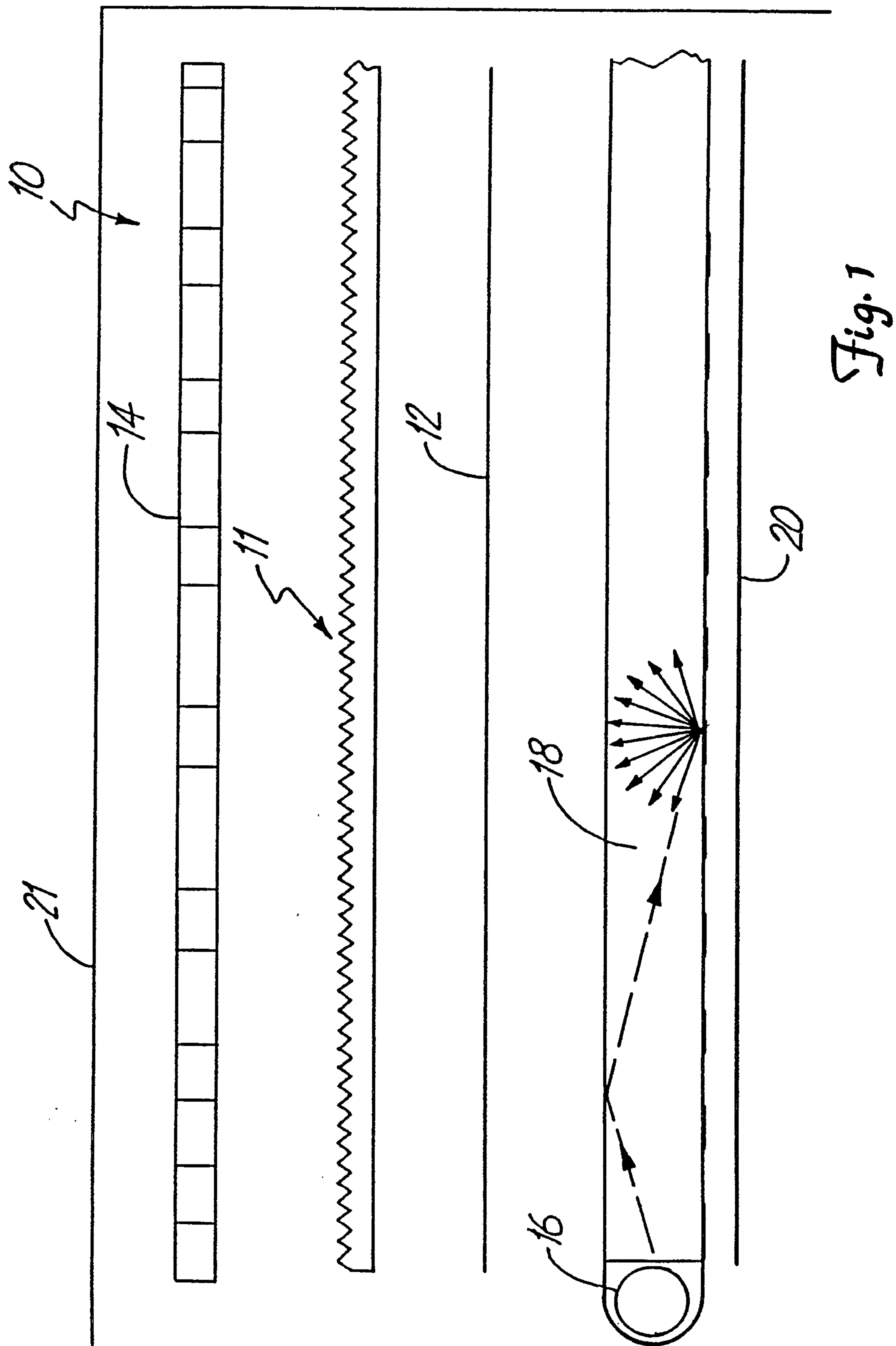
10 a microstructure bearing article as defined in any one of claims 15 to 25 disposed between the light source and display panel.

29. The computer display terminal of claim 28, wherein the display panel is a liquid crystal display panel.

SMART & BIGGAR

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PATENT AGENTS



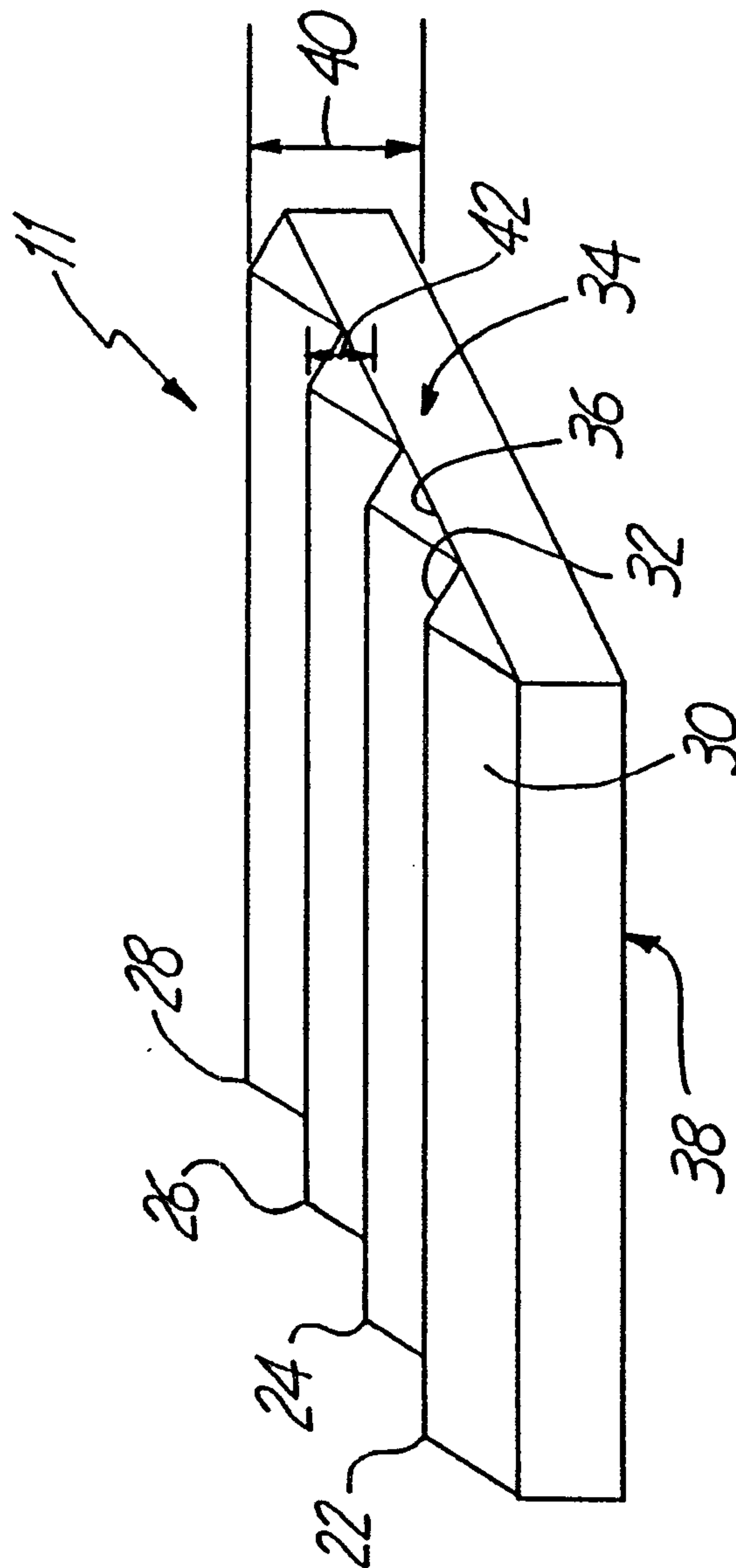


Fig. 2

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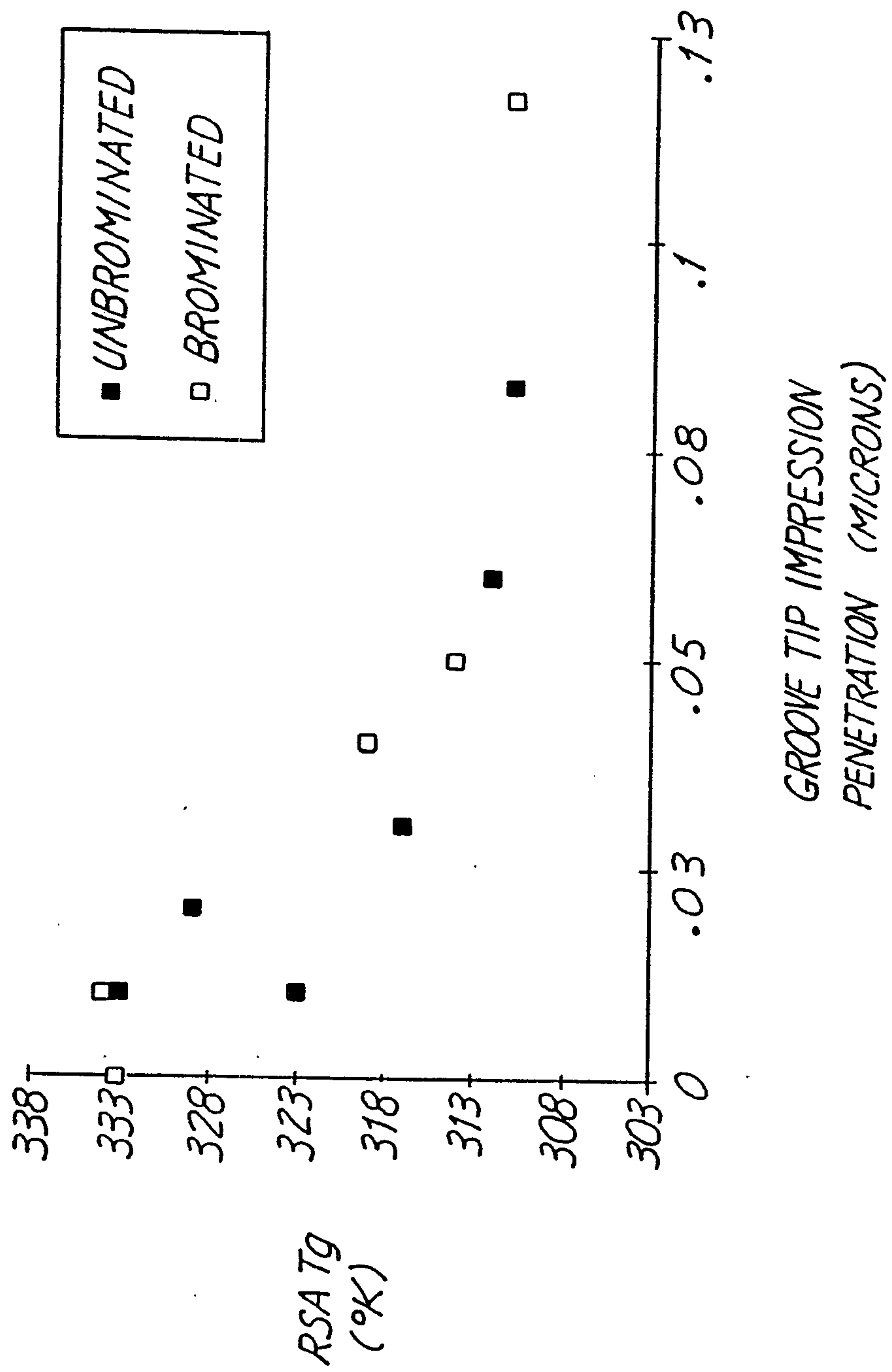


Fig. 3

